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SUPERLATTICE NANOPATTERNING OF WIRES AND COMPLEX PATTERNS

STATEMENT REGARDING FEDERALLY SPONSORED RESEARCH OR DEVELOPMENT

[0001] This invention was made with support from the Defense Advanced Research Projects Agency (DARPA) Grant #MDA972-01-3-0005. The government has a 371 of pet/4503/23546 filed 07/28/2003 certain rights in this invention.

BACKGROUND OF THE INVENTION

1. Field of the Invention

application

[0002] The present invention involves the production of electronic and mechanical devices with length scales measured in nanometers to microns. More particularly, the invention encompasses complicated electrical circuits, mechanical devices, and spatially modulated physical properties. Currently, similar devices (with larger feature sizes) are fabricated using photolithography and related processes often employed by the semiconductor industry.

2. Description of Related Art

[0003] The silicon integrated circuit industry (IC) has dominated electronics and has helped it grow to become one of the world's largest and most critical industries over the past thirty-five years. However, because of a combination of physical and economic reasons, the miniaturization that has accompanied the growth of Si IC's is reaching its limit. The present scale of devices is on the order of tenths of micrometers. New solutions are being proposed to take electronics to even smaller levels; such solutions are directed to constructing nanometer scale devices.

[0004] Prior proposed solutions to the problem of constructing nanometer scale devices have involved (1) utilization of extremely fine scale lithography using Xrays, electrons, ions, or scanning probes to define the device components; (2) direct writing of the device components by electrons, ions, or scanning probes, or (3) using a master fabricated with either process (1) or (2) to stamp the device components into a conformal layer. The major problem with (1) is the capital expense necessary